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A synergetic effect between photogenerated carriers and photothermally enhanced electrochemical urea-assisted hydrogen generation on the Ni-NiO/Nickel Foam catalyst†

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The urea-assisted water electrolysis reactions are of great significance for solving the increasingly serious energy crisis and environmental pollution. Recently, the photo-driven effect strategy has been demonstrated to be an efficient external driving force for improving electrocatalytic activities. Herein, we synthesized Ni-NiO heterostructured nanosheet arrays grown on Ni foam (denoted as Ni-NiO/NF) as a bifunctional electrocatalyst enhancing the urea oxidation reaction (UOR) and hydrogen evolution reaction (HER) activities simultaneously under light irradiation. Moreover, when the catalyst is used in a two-electrode system for the urea-assisted water electrolysis reaction, the cell potential could be reduced to 1.48 V to achieve the current density of 10 mA cm⁻² after exposure to light irradiation, as well as remarkable stability. Our studies demonstrate that the enhancement of the HER & UOR activities is attributed to a synergetic effect between photogenerated carriers and photothermy.

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Introduction

Hydrogen has been considered as a potential green fuel to replace conventional fossil fuels in the future owing to its abundance and zero emissions.^{1,2} Hydrogen production by electrolytic water splitting is a simple and eco-friendly method.³ However, due to the sluggish kinetics of the anodic oxygen evolution reaction (OER), a considerable overpotential is usually required.^{4–6} The overpotential is hopeful to be reduced by replacing the OER with a more efficient oxidation process, such as methanol oxidation reaction,⁷ ethanol oxidation reaction,⁸ selective semi-dehydrogenation of tetrahydroisoquinolines,⁹ electrochemical synthesis of nitric acid¹⁰ and the urea oxidation reaction (UOR).^{11–13} Among these alternative methods, the urea oxidation reaction has been found to be a more efficient and energy-saving alternative

half-reaction with a very low thermodynamic potential of 0.37 V.^{14,15} Thus, urea-assisted water electrolysis, combining the HER and the UOR, can significantly reduce energy consumption.^{16–18} However, the urea oxidation reaction is a very complex reaction involving a 6e⁻ transfer process in the process of gas release (CO(NH₂)₂ + 6OH⁻ → N₂ + CO₂ + 5H₂O + 6e⁻, UOR).^{19,20} Therefore, it is highly desirable to develop a new strategy to improve the reaction rate.

In recent years, light irradiation was introduced into an electrochemical system because it can efficiently improve the electrocatalytic performance. The mechanism might be the generation of hot carriers as well as the photothermal effect *via* excitation of surface plasmon resonance (SPR) effect on noble metal nanomaterials.^{21,22} For example, the plasmonic gold nanostar (AuNSs) can accelerate the electrocatalytic oxidation of ascorbic acid AA *via* LSPR excitation.²³ In addition to noble metals, some semiconducting metal oxides exhibit excellent water splitting performance through a photogenerated-carrier-driven strategy.²⁴ On the other hand, the solar energy can be absorbed and converted into thermal energy to increase the temperature of the catalysts and improve the sluggish kinetics, thus enhancing the electrocatalytic activity.^{25,26} For instance, the operating temperature of the Co₃O₄ electrode is elevated *in situ* under near-infrared (NIR) light irradiation, resulting in enhanced OER activity due to its accelerated electrical conductivity, reaction kinetics, and desorption rate of O₂ bubbles from the electrode.²⁷ It is a promising strategy for increasing the

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conversion efficiency from electrical energy to chemical energy through the utilization of sustainable solar energy.²⁸ Thus, the utilization of photo-driven urea-assisted hydrogen generation is an interesting route and has not been reported yet.

Herein, Ni-NiO heterostructured nanosheet arrays grown on Ni foam (denoted as Ni-NiO/NF) are designed as a bifunctional electrocatalyst for both the UOR and HER. And we have innovatively applied the photo-driven effect on urea electrolysis. Under the illumination of light, the Ni-NiO/NF electrode yields a current density of 10 mA cm^{-2} at potentials of 1.34 V and 119 mV for the UOR and HER, respectively, lower than that without light illumination. Moreover, when the catalyst was used in a two-electrode system for the urea-assisted water electrolysis reaction, the cell potential could be reduced to 1.48 V to achieve the current density of 10 mA cm^{-2} after exposure to light irradiation. Our studies demonstrate that the enhancement of the HER & UOR activities is attributed to a synergetic effect between photo-generated carriers and photothermy.

Experimental

Materials

Ni(NO₃)₂·6H₂O (nickel nitrate hexahydrate, 99%, Tianjin Fuchen Chemical Reagents Co.), HMT (hexamethylenetetramine, ≥99%, Beijing Chemical Corporation), NaBH₄ (sodium borohydride, 98%, Tianjin Fuchen Chemical Reagents Co.), CO(NH₂)₂ (urea, 99%, Sigma-Aldrich), and KOH (Potassium hydroxide, 95%, Tianjin Fuchen Chemical Reagents Corporation) were used.

Synthesis of Ni(OH)₂/NF

Firstly, Ni foam (NF, about $1 \times 1 \text{ cm}^2$) is sonicated with 3 M hydrochloric acid aqueous solution, ethanol, and deionized water for 15 minutes respectively to wash off oxides on the surface. Then, 5 mmol Ni(NO₃)₂·6H₂O and 10 mmol HMT are dissolved in 40 mL distilled water to form a uniform green solution under continuous stirring. The prepared solution and a piece of clean Ni foam are transferred to a 100 mL Teflon-lined stainless-steel autoclave, and then heated at 100 °C for 10 h. After the reaction cools to 25 °C, the obtained NF with green Ni(OH)₂ is washed with distilled water several times and dried at 60 °C in the oven.

Synthesis of Ni-NiO/NF

For the synthesis of the Ni-NiO compound on Ni foam, it is different from previous reports; the as-obtained Ni(OH)₂/NF is directly calcined in N₂ atmosphere at 300 °C for 2 h with 0.30 g NaBH₄ at the upstream side of the porcelain boat. When the temperature is cooled down, the black film Ni-NiO/NF is finally obtained.

Characterization

Field emission scanning electron microscopy (FESEM, GeminiSEM 300) was used to obtain the morphology of the samples, and transmission electron microscopy (TEM, FEI Tecnai G2 F20) was used to confirm the microstructures of the catalysts. The crystal structures of the samples were measured using X-ray diffraction (XRD, D8-Advance; Bruker Miller), X-ray photoelectron

spectroscopy (XPS, Axis Ultra; Kratos Analytical Ltd) was used to study the valence state of the elements, and Raman spectroscopy was recorded under the excitation of 532 nm laser light with a power of 20 mW. The UV-Vis absorption spectra were collected at 200–800 nm against the BaSO₄ reflectance standard. The real-time sample temperatures were measured using an IR thermograph (Ou PuShi PI450) during the experiment, and a 300 W Xe lamp (PLS-SXE 300C, Beijing Perfectlight Technology Co., Ltd, China) was used to simulate the full spectrum of solar light.

Electrochemical measurements

The electrochemical measurements are conducted using an electrochemical workstation (VMP3, SP-240, Bio-logic, France) in a three-electrode system. The as-obtained samples on Ni foam were used as the working electrode, a graphite rod was used as the counter electrode and a Hg/HgO (1 M KOH) electrode was used as the reference electrode. The electrolyte was 1 M KOH with and without 0.33 M urea aqueous solution. In all the measurements, the potentials used were converted into RHE, $E_{(\text{RHE})} = E_{(\text{Hg/HgO})} + 0.059\text{pH} + 0.098 \text{ V}$. The catalytic performance of the three samples for the UOR and HER were evaluated by linear sweep voltammetry (LSV) at a scan rate of 10 mV s^{-1} . Cyclic voltammetry (CV) is conducted with a scan rate of 50 mV s^{-1} . Electrochemical impedance spectroscopy (EIS) was recorded in the frequency range from 100 kHz to 0.1 Hz with a voltage amplitude of -0.096 V in HER tests and 1.354 V in UOR tests. Chronoamperometry of UOR was tested in 1.354 V vs. RHE and HER was tested in -0.106 V vs. RHE. We sweep the potential between 0.6 to 0.8 V vs. RHE at each of seven different scan rates (20, 40, 60, 80, 100, 120, and 140 mV s^{-1}). By plotting the difference in current density (j) between anodic and cathodic sweeps ($j_a - j_c$) at a fixed potential against the scan rate, a linear trend is observed. The fitting slope is twice the double-layer capacitance (C_{dl}), which is linearly proportional to the ECSA. Urea electrolysis tests were measured in a two-electrode system with Ni-NiO/NF as the anode and cathode. The long-term durability of the Ni/NiO-NF electrode was assessed at constant voltage (1.45 V) electrolysis. All data for the two electrode tests were recorded without iR correction.

Light illumination is obtained by passing light from a 300 W Xenon lamp (PLS-SXE 300C, Beijing Perfectlight Technology Co., Ltd, China) and the power intensity of the incident light is calibrated to 150 mW cm^{-2} at the surface of the working electrode. The light we used in the test of the photothermal part in this experiment is full spectrum light. The effect of irradiation wavelengths on the HER and UOR performance is investigated under various monochromatic lights which are obtained by using a series of band-pass filters (350 nm, 400 nm, 450 nm, 500 nm, 550 nm). The chronopotentiometric curve is measured at -0.079 V versus RHE for the HER and 1.424 V versus RHE for the UOR to examine the electrochemical stability of Ni-NiO/NF without and with irradiation.

Results and discussion

The Ni-NiO/NF is synthesized through a hydrothermal route and the subsequent calcination reduction under the N₂ atmosphere



with NaBH_4 . The SEM images of precursor $\text{Ni}(\text{OH})_2/\text{NF}$ are displayed in Fig. 1a. $\text{Ni}(\text{OH})_2$ nanosheets were grown on commercial Ni foam (SEM image of NF see Fig. S1, ESI[†]), and the nanosheets were a few nanometers thick. As shown in Fig. 1b and c, the SEM images of Ni-NiO/NF show that the nanosheet array remains unchanged but nanoparticle morphologies of the reduced Ni were observed. The TEM image (Fig. 1d) of Ni-NiO/NF also shows the two types of morphologies, in agreement with the SEM image results (Fig. 1c). The average diameter of the Ni nanoparticles of the sample was approximately 30 nm, which forms heterojunctions with nanosheets. The HRTEM image (Fig. 1e) shows a lattice fringe of 0.202 nm, corresponding to metal Ni (111) nanoparticles and a distance of 0.208 nm that can be indexed to the (200) plane of NiO. Fig. 1f exhibited two lattice fringe spacings of 0.238 and 0.173 nm, which were assigned to the (111) of NiO and (200) of Ni, respectively. The obtained HR-TEM images confirmed that the nanosheets were coexisting NiO and Ni, and the formation of Ni nanoparticles was attributed to the NaBH_4 reduction steps. The Raman spectra (Fig. 1g) show two peaks at about 520 cm^{-1} and 1090 cm^{-1} which are attributed to the vibration modes of Ni-O bonds of NiO. The X-ray diffraction (XRD) patterns (Fig. S2, ESI[†]) indicate one weak diffraction peak at 43.3° which is believed to be the (200) of NiO in Ni-NiO/NF.²⁹ The NiO phase with low crystallinity and the weak diffraction peak is caused by the strong peak signal of Ni. X-ray photoelectron spectroscopy (XPS) measurements of $\text{Ni}(\text{OH})_2/\text{NF}$ and Ni-NiO/NF were also conducted to study the chemical states of Ni and O species. As shown in Fig. 1h, for $\text{Ni}(\text{OH})_2/\text{NF}$,

the peaks centered at 855.1 eV and 856.6 eV can be assigned to Ni^{2+} and Ni^{3+} , respectively. The peak is located at 861.2 eV accompanied by the satellite peak. Compared with $\text{Ni}(\text{OH})_2/\text{NF}$, a peak at 853.4 eV appeared in the Ni-NiO/NF, indicating the existence of metallic Ni species; in particular, the peaks of Ni^{2+} and Ni^{3+} shifted toward lower binding energy, implying that oxygen vacancies might be generated during the reduction process.^{30,31} Similarly, as displayed in the O 1s spectrum (Fig. 1i), there are two peaks in $\text{Ni}(\text{OH})_2/\text{NF}$ and three peaks in Ni-NiO/NF. For $\text{Ni}(\text{OH})_2/\text{NF}$, the peak at 530.9 eV is assigned to OH^- groups and the peak at 531.7 eV is mainly assigned to the surface-adsorbed groups. For Ni-NiO/NF, the peak at 531.7 eV can be attributed to the adsorbed oxygen species which is the same as $\text{Ni}(\text{OH})_2/\text{NF}$ and another peak at 530.9 eV is assigned to the oxygen vacancies. Additionally, the peak at 529.3 eV corresponds to the lattice oxygen of NiO species.^{32,33} The full XPS spectrum of Ni-NiO/NF demonstrated the presence of Ni, O and C species with 36%, 40% and 24% atomic concentration, respectively (Table S1, ESI[†]).

As a highly efficient photothermal material, the first requirement is a wide light adsorption capability.³⁴ To determine the light absorption performances of the Ni-NiO/NF electrode, UV-vis absorption spectra of the Ni-NiO/NF and NF were measured. As displayed in Fig. 2a, both Ni-NiO/NF and NF exhibit absorption in ultraviolet, visible, and near-infrared regions. Compared with NF, the Ni-NiO/NF composites showed more absorbance over the whole wavelength range, demonstrating that Ni-NiO/NF exhibits a stronger near-infrared light absorption ability

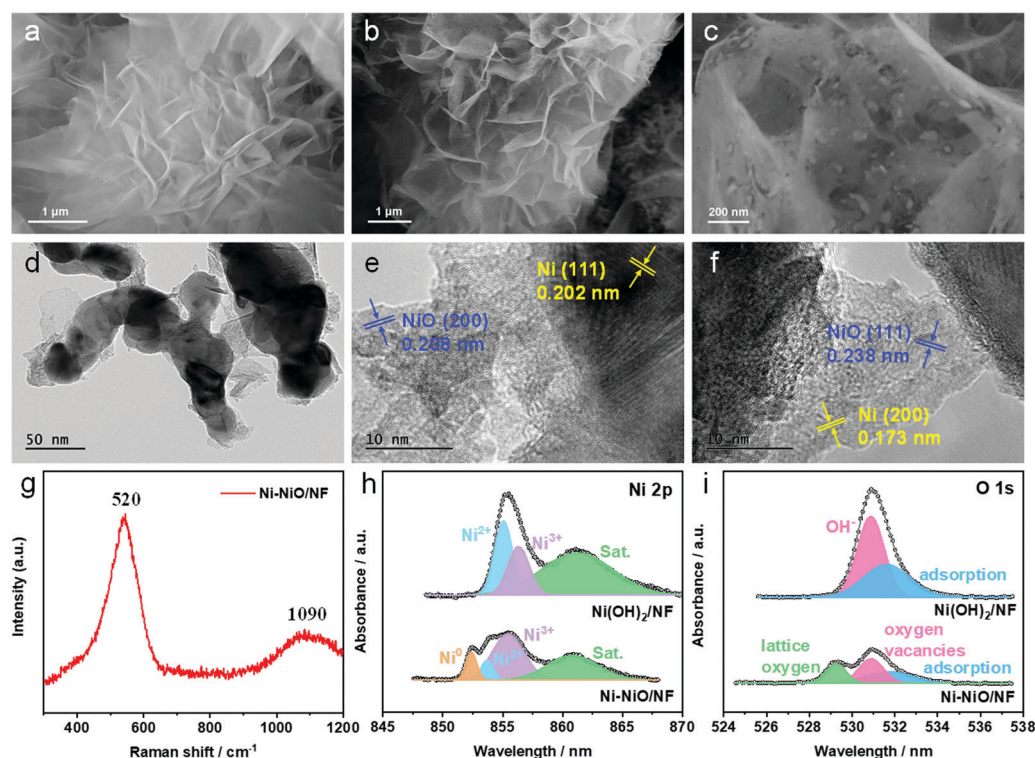


Fig. 1 (a) SEM image of the precursor $\text{Ni}(\text{OH})_2/\text{NF}$. (b) Low-magnification SEM image, (c) high-magnification SEM image, (d) TEM image, and (e and f) HRTEM image of Ni-NiO/NF. (g) Raman spectrum of Ni-NiO/NF. XPS spectra of (h) Ni 2p and (i) O 1s in the sample of Ni-NiO/NF.



than NF. To investigate the photothermal effect of Ni-NiO/NF, the sample was placed in water under the illumination of a 300 W Xe lamp with the intensity of 150 mW cm^{-2} and the infrared camera was used to probe the surface temperature of the sample. As shown in Fig. 2b, the temperature of Ni-NiO/NF increases rapidly from 26.21°C to 41.47°C (Fig. S3, ESI†) within 60 s and was finally maintained at 48.98°C . The rapid temperature rises at the initial stage revealed that the sample has a high efficiency from light energy to thermal energy. Fig. 2c shows the time-dependent temperature curves of Ni-NiO/NF, Ni(OH)₂/NF, and NF in the water with and without irradiation of light. All the samples were kept at the same initial temperature without irradiation, and then the temperature of the three samples increased rapidly under light irradiation. As the exposure time increases, the temperature rises slowly; when the irradiation of light was turned off, the temperature of all three materials dropped rapidly. It can be seen that Ni-NiO/NF exhibited the highest temperature of 36.69°C which was higher than Ni(OH)₂/NF (34.52°C) and NF (35.31°C). The corresponding infrared images are shown in Fig. S4 (ESI†). Therefore, the explanation might be that the Ni foam is a kind of material with a good photothermal effect, and when Ni-NiO nanosheets covered the Ni foam surface, due to their improved absorptance, the surface temperature was higher than using the Ni foam alone.

The UOR tests were carried out through a conventional three-electrode cell in 1 M KOH with 0.33 M urea. Fig. 3a shows a comparison of the CV curves using Ni-NiO/NF catalysts in 1 M KOH solution in the absence and presence of 0.33 M urea. Compared with the CV curve in 1 M KOH solution, high current density was observed in the curve of the sample in 1 M KOH with 0.33 M urea solution after 1.35 V vs. RHE, indicating high activity of the catalyst for urea oxidation. Linear sweep voltammetry (LSV) curves for the UOR and OER of the Ni-NiO/NF are shown in Fig. S5 (ESI†). The peaks at about 1.37 V for the OER curves can be attributed to the redox pair of $\text{Ni}^{2+}/\text{Ni}^{3+}$.³⁵ For comparison, the polarization curves of the Ni-NiO/NF, Ni(OH)₂/NF, and NF electrodes in 1.0 M KOH with 0.33 M urea were displayed in Fig. 3b; in particular, the Ni-NiO/NF electrode demonstrated the best UOR performance among the samples. The onset potential is 1.35 V, which is close to the potential at the beginning of the Ni redox, indicating that the newly formed NiOOH species is active for urea oxidation.³⁶ Specifically, the current density of

10 mA cm^{-2} of Ni-NiO/NF requires only a small potential of 1.36 V vs. RHE, which is lower than that of Ni(OH)₂/NF (1.37 V) and the NF substrate (1.39 V). Notably, the polarization curves of the NF had an obvious oxidation peak at $\sim 1.56 \text{ V}$ vs. RHE, which can be explained as the poor performance of NF for urea oxidation, and nickel foam has priority over its own oxidation of Ni^{2+} to Ni^{3+} . The improved kinetics of the sample were also confirmed by the Tafel slopes (Fig. 3c). Ni-NiO/NF had the much lower Tafel slope of 32 mV dec^{-1} , whereas Ni(OH)₂/NF and NF had the values of 48 and 60 mV dec^{-1} , respectively.

After exposure to the illumination by a 300 W Xenon lamp with an intensity of 150 mW cm^{-2} , Ni-NiO/NF exhibits significantly enhanced UOR activities (Fig. 3d). The onset potential decreases from 1.35 to 1.33 V, and the overpotential reduces to 1.34 V to achieve a current density of 10 mA cm^{-2} . When light irradiation was replaced by a water bath of 49°C , the overpotential was 1.36 V for a current density of 10 mA cm^{-2} , which is equal to that without illumination. For comparison, the UOR performance of nickel foam with and without light illumination was also tested (Fig. S6, ESI†). The UOR activities of NF were almost the same before and after illumination. The results showed that the nickel foam could not improve the UOR activities under light conditions. The outstanding UOR catalytic behavior of Ni-NiO/NF under illumination is further evidenced by the Tafel plots shown in Fig. 3e. An obviously lower Tafel slope of 28 mV dec^{-1} for Ni-NiO/NF-(light) is observed in comparison to that in other conditions. Besides, electrochemical impedance spectroscopy (EIS) tests were also conducted to show solution resistance (R_s) and charge transfer resistance (R_{ct}) during urea oxidation (Fig. S7, ESI†). This result shows that the Ni-NiO/NF electrode displays smaller R_{ct} and R_s under light illumination in contrast to that without light illumination. For a clear comparison, the voltages to reach current densities of 10, 100, 200, and 300 mA cm^{-2} of Ni-NiO/NF in different conditions are listed in Fig. 3f. It can be seen that a water bath facilitates the reaction kinetics to enhance the electrocatalytic UOR performance. However, the UOR performance for the Ni-NiO/NF electrode enhanced significantly under illumination, which is superior to that in a water bath.

To further understand the enhanced electrocatalytic activities of Ni-NiO/NF under irradiation, intermittent irradiation was applied to the Ni-NiO/NF electrode (Fig. 3g). When the electrode

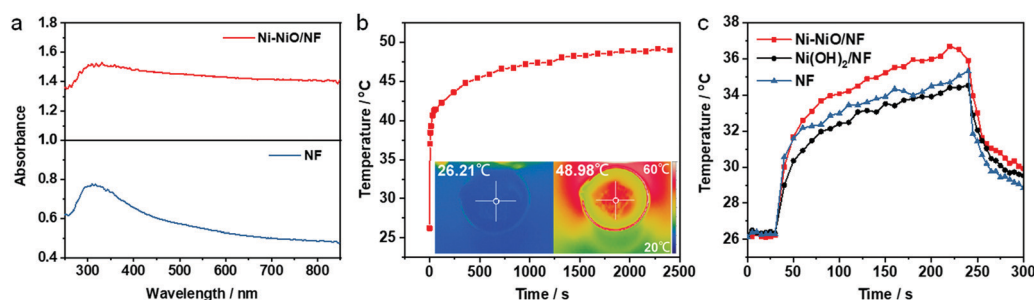


Fig. 2 (a) UV-vis absorbance spectra of Ni-NiO/NF and NF. (b) Time-dependent temperature curve of Ni-NiO/NF in the water under the irradiation of full spectrum light. Inset shows infrared thermal images of Ni-NiO/NF in the water before irradiation (left) and after irradiation (right) for 2400 s. (c) Time-dependent temperature curves of Ni-NiO/NF, Ni(OH)₂/NF and NF in the water with and without irradiation of light for 300 s.



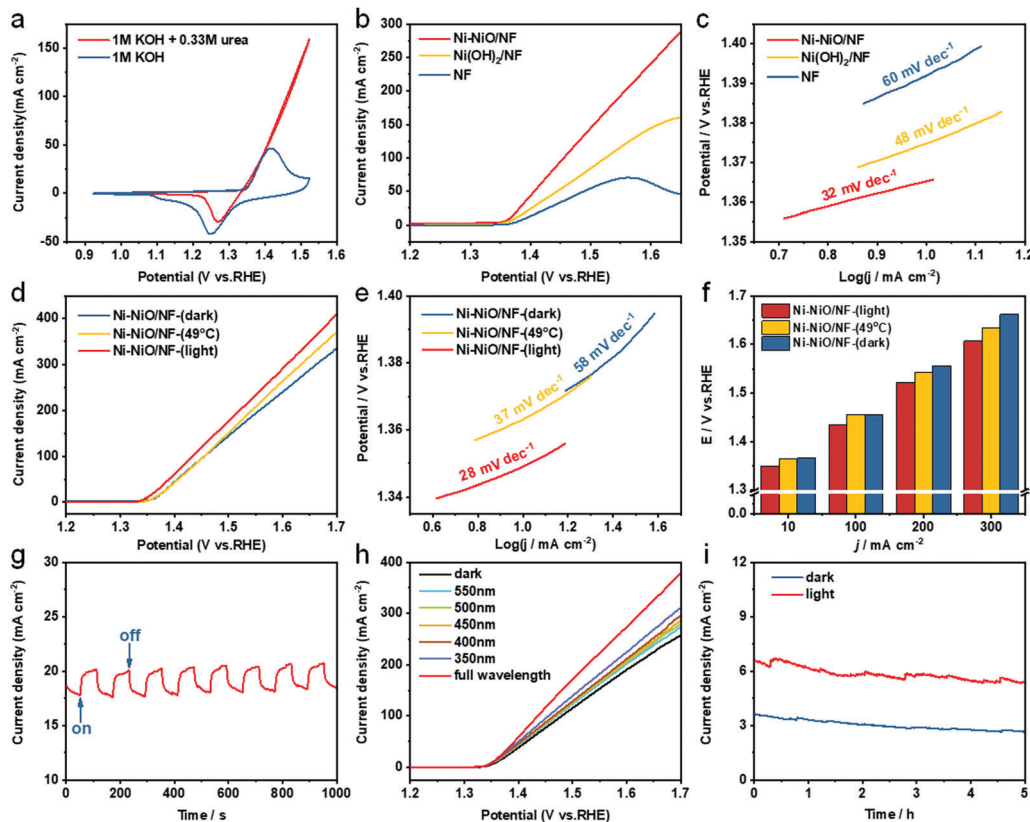


Fig. 3 (a) Cyclic voltammograms of Ni-NiO/NF in 1 M KOH and 1 M KOH with 0.33 M urea. (b) Polarization curves of Ni-NiO/NF, Ni(OH)₂/NF and NF in 1 M KOH with 0.33 M urea electrolyte at 10 mV s⁻¹. (c) Tafel slopes of Ni-NiO/NF, Ni(OH)₂/NF and NF for the UOR. (d) UOR polarization curves of Ni-NiO/NF under the conditions of darkness, irradiation, and a water bath (49 °C) in 1 M KOH with 0.33 M urea electrolyte. (e) Corresponding Tafel plots. (f) Voltage required to reach different current densities of the Ni-NiO/NF under different conditions. (g) Current density–time curve of the Ni-NiO/NF electrode during the UOR at a potential of 1.424 V vs. RHE under intermittent illumination. (h) UOR polarization curves of Ni-NiO/NF with different wavelengths of irradiation. (i) Time–dependent current density curves of Ni-NiO/NF without and with irradiation at 1.354 V vs. RHE for the UOR.

was under illumination, the current density obviously increased. When the illumination was turned off, the current density returned to the initial value rapidly. This result shows that the UOR performance can be enhanced on the Ni-NiO/NF electrode by photogenerated carriers from the excited NiO.³⁷ The effect of irradiation wavelengths on UOR performance was displayed in Fig. 3h. The UOR activity increased with a decrease in wavelength. As is well-known, photo-generated carriers are more easily excited at shorter wavelengths, while larger wavelengths can generate more thermal energy. Therefore, it indicates the effect of photo-generated carriers on UOR performance. Moreover, the band gap value of the p-type semiconductor NiO is 3.5 eV, but the performance is also improved with irradiation wavelength greater than 350 nm, which may due to defects on the catalyst. Furthermore, the chronoamperometry test was conducted at a potential of 1.354 V vs. RHE with and without irradiation. The steady current density of the Ni-NiO/NF catalyst may achieve 5.7 mA cm⁻² under irradiation, which is higher than that (2.9 mA cm⁻²) without irradiation. This indicated that the Ni-NiO/NF electrode had good stability and the high durability of the irradiation-driven enhanced electrocatalytic activity (Fig. 3i).

The HER activity of Ni-NiO/NF was investigated in 1 M KOH with and without light irradiation. The polarization curves

displayed that the HER activities of Ni-NiO/NF enhanced significantly after exposure to illumination. The overpotential decreases from 158 to 119 mV at 10 mA cm⁻² current density (Fig. 4a). The corresponding Tafel slopes obtained from the LSV curves are shown in Fig. 4b. The Tafel slope of the Ni-NiO/NF electrode with irradiation was 131 mV dec⁻¹, which is superior to that of the Ni-NiO/NF electrode without irradiation (151 mV dec⁻¹), indicating that the HER reaction kinetics of the Ni-NiO/NF electrode can be efficiently facilitated by light irradiation. The effect of irradiation monochromatic light with different wavelengths from 350 nm to 550 nm on HER performance was displayed in Fig. 4c. The HER performances were also performed in the same order with UOR: Ni-NiO/NF-(350 nm) > Ni-NiO/NF-(400 nm) > Ni-NiO/NF-(450 nm) > Ni-NiO/NF-(500 nm) > Ni-NiO/NF-(550 nm). In addition, Ni-NiO/NF exhibits a rapid reproducible current response to the light on and off cycles at the HER typical potential (Fig. 4d). These results also demonstrate that the photo-generated carriers *via* photo-excited semiconductors enhanced the electrocatalytic performance. In order to investigate the photothermal effect on the electron transfer ability of the Ni-NiO/NF electrode, electrochemical impedance spectroscopy (EIS) measurements were further conducted, as shown in Fig. 4e. The EIS result has shown that the catalyst with light illumination



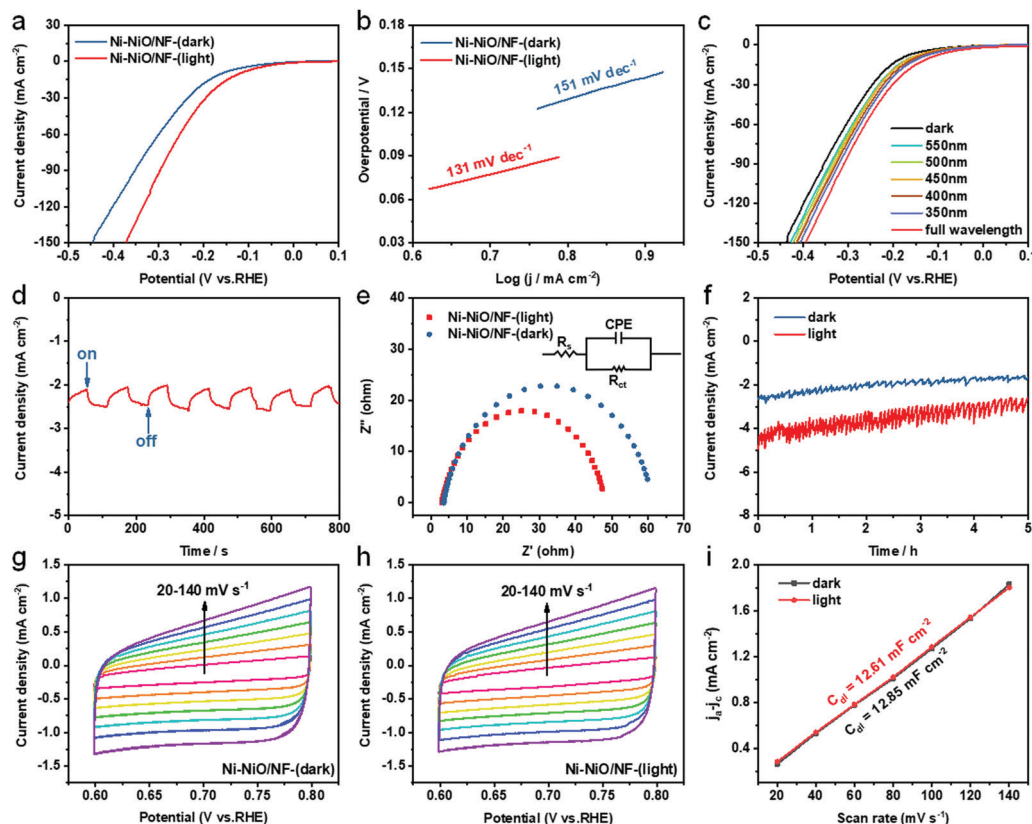


Fig. 4 (a) HER polarization curves of Ni-NiO/NF under the conditions of darkness and irradiation in 1 M KOH electrolyte at 10 mV s^{-1} . (b) Corresponding Tafel plots. (c) HER polarization curves of Ni-NiO/NF with different wavelengths of irradiation. (d) Current density–time curve of the Ni-NiO/NF electrode during the HER at a potential of -0.079 V vs. RHE under intermittent illumination. (e) Nyquist plots of Ni-NiO/NF at -0.096 V vs. RHE. (f) Time–dependent current density curves of Ni-NiO/NF without and with irradiation at -0.106 V vs. RHE for the HER. (g and h) CV curves for Ni-NiO/NF between 0.6 V and 0.8 V vs. RHE in 1 M KOH at various scan rates. (i) Plots showing the extraction of double-layer capacitance of C_{dl} for Ni-NiO/NF under the conditions of darkness and irradiation.

possesses a much smaller charge transfer resistance (R_{ct}) in contrast to that without light illumination, indicating faster electron transport. Furthermore, the stabilities of HER with light illumination exhibit higher current density over time than that without light illumination (Fig. 4f). The periodic fluctuation may be due to the accumulation and removal of generated H_2 bubbles on the electrode surface.

Moreover, to further ascertain the effect of illumination on the active sites, the electrochemical active surface areas (ECSAs) of the Ni-NiO/NF electrode with and without light illumination were estimated by extracting the electrochemical double-layer capacitance (C_{dl}) from the CV measurements (Fig. 4g and h). And the capacitance is usually considered to be proportional to the electrochemical active area.³⁸ It is found that the C_{dl} of Ni-NiO/NF under illumination (12.61 mF cm^{-2}) is close to that without illumination (12.85 mF cm^{-2}) (Fig. 4i). Hence, the improved performance of Ni-NiO/NF in the UOR and HER with illumination cannot be explained by the improved active surface area and increased active sites. As a result, the significantly improved activity should be mainly ascribed to the increased electronic density and the optimized reaction kinetics.

Inspired by the remarkable catalytic abilities of the Ni-NiO/NF electrode for the UOR and HER, a two-electrode electrolyzer

was constructed to estimate the performance of electrochemical hydrogen generation with the Ni-NiO/NF electrode as both the anode and cathode (Fig. 5a). As shown in Fig. 5b, the cell voltage needed by the Ni-NiO/NF||Ni-NiO/NF in the electrolyzer in 1 M KOH + 0.33 M Urea with illumination to achieve the current density at 10 mA cm^{-2} is 1.48 V , which is lower than that without illumination (1.54 V), clearly showing the superior cell efficiency of urea oxidation assisted H_2 production under illumination. It can be concluded that the assistance of urea oxidation can lower the energy consumption of hydrogen production. Moreover, the Ni-NiO/NF electrode demonstrated excellent performance in urea-assisted electrochemical hydrogen production when compared with other reported materials (Table S2, ESI†). Furthermore, the stability of the Ni-NiO/NF||Ni-NiO/NF in the HER-UOR electrolyser was tested at 1.45 V in 1 M KOH + 0.33 M urea with and without irradiation for 5 h (Fig. 5c). The current density decreased in the first hour and then achieved equilibrium and remained constant during 4 h. Moreover, the current density under irradiation is 4 mA cm^{-2} , which is 2-fold higher than that without irradiation (2 mA cm^{-2}), suggesting the good stability of the irradiation-driven enhanced urea electrolysis. The morphology and surface chemical states of the Ni-NiO/NF catalyst were further probed by the SEM, TEM, XRD and XPS techniques after the



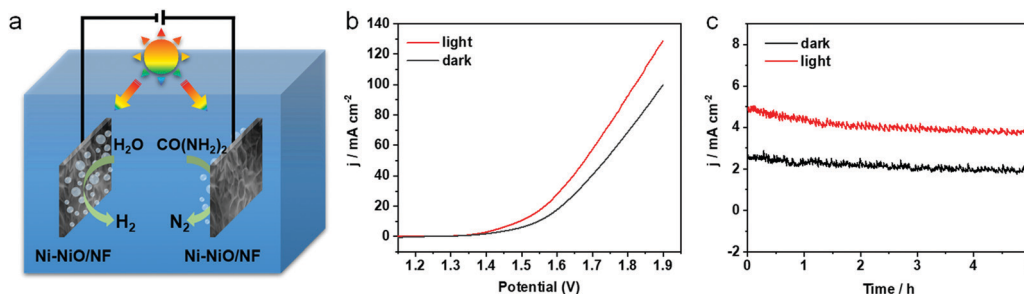


Fig. 5 (a) The schematic shows the urea electrolyser using Ni-NiO/NF as the anode and cathode in 1 M KOH with 0.33 M urea. (b) Comparison of polarization curves for urea electrolysis under the conditions of darkness and irradiation. (c) The long-term stability test of urea electrolysis performed at a cell voltage of 1.45 V.

durability test (Fig. S8, ESI[†]). The nanosheet array morphology of Ni-NiO/NF was still maintained, as confirmed by the SEM and TEM images (Fig. S8a and 8b, ESI[†]). The fringes assigned to the (111) plane of Ni and the (200) plane for NiO were still discovered, and a new fringe of 0.241 nm assigned to the interplanar spacing of the (002) plane of β -NiOOH was found, suggesting the formation of high valence Ni species during the electrochemical catalytic process (Fig. S8c, ESI[†]). The XRD patterns still indicate one weak diffraction peak at 43.3° which is believed to be the (200) of NiO (Fig. S8d, ESI[†]). According to the XPS Ni 2p spectrum given in Fig. S8e (ESI[†]), the peak of Ni^{3+} is larger than that before the reaction, indicating high valence Ni species of β -NiOOH. Fig. S8f (ESI[†]) shows that the oxygen adsorption on the surface increases. The surface oxidation and Ni^{3+} increase due to the catalyst surface was significant for the high catalytic ability and durability of the Ni-NiO/NF catalyst in urea-assisted water electrolysis.

Conclusions

In summary, the Ni-NiO/NF electrodes exhibit exceptional catalytic performance for the UOR and HER by the photo-driven effect strategy. This hybrid catalyst could be synthesized through a facile hydrothermal method and subsequent calcination reduction processes. Under illumination, the overpotential of the UOR decreases from 1.36 V to 1.34 V at 10 mA cm^{-2} and it decreases 39 mV at 10 mA cm^{-2} for the HER. Furthermore, a two-electrode electrolyser composed of Ni-NiO/NF electrodes as both the anode and cathode requires a small voltage of 1.48 V under illumination to attain 10 mA cm^{-2} , indicating the excellent urea-assisted water electrolysis activity. It is found that the greatly enhanced HER & UOR activities can be ascribed to the efficient light absorption and subsequent conversion to thermally accelerated Ni-NiO/NF reaction kinetics. Another reason is that the photogenerated electron transfer of the excited NiO can enrich electronic density, thereby improving the activity. This work may open new approaches to fabricate high-efficiency bifunctional electrocatalysts for urea oxidation assisted H_2 production by using the renewable power of solar energy.

Author contributions

Qi Wang: Conceptualization, Methodology, Investigation, Writing-original draft; Xing Cheng: Formal analysis, Data curation; Yukun

Sun: Validation, Data curation; Zaicheng Sun: Data curation; Dong Wang: Writing-review & editing; Ge Chen: Writing-review & editing, Supervision; Peter Schaaf: Writing-review & editing.

Conflicts of interest

There are no conflicts to declare.

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